

Going deep into chemical burns

Wang CY, Su MJ, Chen HC, Ou SY, Liu KW, Hsiao HT.

Annals of the Academy of Medicine, Singapore

1992; 21(5):677-681

ARTICLE IDENTIFIERS

DOI: unavailable

PMID: 1292400

PMCID: not available

JOURNAL IDENTIFIERS

LCCN: not available

pISSN: 0304-4602

eISSN: 2972-4066

OCLC ID: 01145745

CONS ID: sn 82004501

US National Library of Medicine ID: 7503289

This article was identified from a query of the SafetyLit database.